

Advances in Thin-Film Solar Cells

Second Edition





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Preface to the Second Edition

Light energy was first converted into electricity by Edmund Becquerel in 1839, but until the 1950s, no considerable development had taken place. However, during the two decades of the 1950s and the 1960s, Si-based solar cells were developed, manufactured, and applied in applications such as satellites and remote communication stations. The first oil crisis, in the early 1970s, gave a huge push to the search for alternative energy conversion methods, and researchers actively searched for new materials and low-cost device structures. As a result, thin-film solar cells based on III-V compounds (GaAs and InP), amorphous Si, CdTe, and CuInGaSe₂ (CIGS) were introduced to mainstream solar energy conversion. In the early 1990s, dye-sensitised solar cells were introduced by Michael Grätzel, and organic solar cells were introduced in the early 2000s. With the renewed interest in nanomaterials, researchers worldwide are exploring the ways of using new materials such as perovskites in solar cell devices. At present, all these photovoltaic (PV) fronts are moving toward producing low-cost and high-efficiency solar cells to convert sunlight into electricity.

The main hurdle in the rapid market penetration of solar energy applications is their high cost. Although there are active research programmes to reduce manufacturing costs and increase conversion efficiencies, the progress is painfully slow for various reasons—one reason being the lack of deeper understanding of material issues and physics behind solar cell devices. This book does not deal with well-documented semiconductor properties and device principles but presents the latest developments and advances in thin-film solar cells, with an introduction to the most required background knowledge. The targeted audience will be undergraduate and postgraduate students in science and engineering; electronic device researchers in chemistry, material science, physics, mathematics, and engineering; and PV module developers and technologists in the industry. This book concentrates mainly on advances in thin-film solar cells based on CdTe-, CIGS-, and GaAs-based devices, but the ideas are equally applicable to all thin-film solar cells.

Chapter 1 introduces solar energy conversion to all readers in a simple manner with the aid of diagrams, references, and animations placed on the author's website. The next chapter provides a brief status report on PV technology. The main barrier in the PV sector is the high manufacturing cost due to the use of expensive materials (Si and III-V compounds) and the high energy consumption during materials growth and device processing. The initial high capital cost of equipment also exacerbates this situation. As a solution to this, a low-cost and scalable materials growth technique (electro-chemical deposition) for II-VI and alloy compounds will be described in Chapter 3. This growth method is also a suitable low-cost technique for growing nanomaterials for various other applications in nanotechnology. In all solar cells, two electrical contacts are needed to extract the photo-generated charge carriers from the device and, hence, these metal/semiconductor (MS) interfaces play a very important role in the overall performance. Chapter 4 summarises the most striking recent breakthroughs which improved the understanding of PV action in thin-film solar cells. This chapter describes the history of the CdTe solar cell, the application of new ideas to this device, the formation of a new concept to describe the solar energy conversion process, and the way forward for the development of the device. Chapter 5 extends the applicability of the Fermi-level pinning concept to CIGS-based solar cells. The next three chapters are devoted to revisiting the current practice in tandem solar cells based on tunnel junctions and the use of multi-layer graded bandgap device structures in solar energy conversion. The latter device design has been tested with a well-researched GaAs/AlGaAs system and experimentally observed the highest reported 1,175 mV open circuit voltage with the highest achievable fill factor of \sim 0.86 for a single device. The new device concept is mainly based on a set of defects within these devices, and Chapter 9 describes the effects of defects on

the performance of solar cells. It also describes the way forward for dealing with defects in order to achieve higher performance in devices. Chapter 10 is new in the second edition. It summarises the progress of graded bandgap devices fabricated using electroplated materials during the two years (2014-2016), achieving 15.3% efficiency. Chapter 11 is for the general public and describes the scenario of a future dominated by solar energy. This is based on author's 27 years of public understanding of science activities and real projects carried out on the ground. The solar village project designed and piloted successfully by the author is described, and the replication programme is indicated in this chapter. There are two short chapters included at the end of this book—Chapter 12 presents the evidence collated to date for Fermi-level pinning in GaAs-based solar cells, and Chapter 13 indicates some thoughts on future directions of thin-film solar cell research. In this second edition, relevant exercises and their solutions have been included. and these will be really useful for academics teaching in this field.

I am grateful to all the people who have supported me to develop and progress in this sector. My PhD supervisors, late Sir Professor Gareth Roberts and Professor Mike Petty at Durham University, put me on the right track at the very beginning, in the late 1970s. Working with active scientists in the field. Professors R. H. Williams and E. H. Rhoderick, enabled me to be well established in this field during my four-year postdoctoral research in University College Cardiff, in early 1980s. Since then, I have worked on and learned the subject from numerous colleagues from chemistry, physics, mathematics, and engineering disciplines, both in academia and in the industry (BP Research, Sunbury). During the last 28 years of my academic career at Sheffield Hallam University, many postdoctoral researchers, 28 PhD students, and numerous visiting researchers contributed to this work in order to understand the chemistry and physics behind these complex materials and devices. University lecturing on relevant subjects like electricity and magnetism, thermodynamics, solid-state physics, quantum mechanics, highspecification materials, device design and manufacture, optical fibre communication, engineering product analysis and design and Si processing in clean room environment for over three decades helped me in understanding these complex devices. This accumulated knowledge, new breakthroughs and recent advances are presented in this book to share with the present and future scientists, engineers, and the general public. I am grateful to my immediate family for their help and support during this journey. In particular, I thank Dahiru Diso, Gavin Tolan, Jayne Wellings, Gafar Muftah, Osama Elsherif, Ajith Weerasinghe, Kingsley Obi Echendu, Fijay Bin Fauzi, Azlian Abdul-Manaf, Olusola Olajide, Mohammed Madugu, Salim Hussein, Ojo Ayotunde, Ruvini Dharmadasa, and Asela Dharmadasa for their contributions during the preparation of this book. I also thank Sidath Kalyanaratne, Nishith Patel, and Ashfaque Alam for preparing some of the diagrams used in this book.

Finally, this book is dedicated to my beloved parents, who worked hard to support me during my childhood with limited resources while living in the sun-rich environment of Sri Lanka. I am hopeful that this book will contribute to reverse this situation for future generations by bringing prosperity to all the people who live wherever the sun is shining.

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List of Symbols and Abbreviations

- *f* frequency in Hz
- e electronic charge
- k Boltzmann constant
- χ electron affinity
- ε_0 dielectric permittivity of free space
- $\varepsilon_{\rm s}$ dielectric permittivity of semiconductor
- ε_r relative permittivity of semiconductor
- σ electrical conductivity
- *T* temperature in Kelvin
- $\varphi_{\rm b}$ potential barrier height
- $\varphi_{\rm m}$ metal work function
- $E_{\rm g}$ energy bandgap of a semiconductor
- *A** Richardson constant for thermionic emission
- *S* area of a solar cell
- *n* ideality factor of a diode
- *V*_{oc} open circuit voltage of solar cells
- *I*_{sc} short circuit current of solar cells
- *J*_{sc} short circuit current density of solar cells
- FF fill factor, or curve factor, of solar cells
- η solar to electric power conversion efficiency
- CdTe cadmium telluride
- CIGS copper indium gallium diselenide
- GaAs gallium arsenide
- AlAs aluminium arsenide